A P V No b							
Application Number:	10.	10737393					
Filing Date:	16-	16-Dec-2003					
Title of Invention:	FO	MASK BLANK FOR CHARGED PARTICLE BEAM EXPOSURE, METHOD OF FORMING MASK BLANK AND MASK FOR CHARGED PARTICLE BEAM EXPOSURE					
First Named Inventor/Applicant Name:	Ke	Kenichi Morimoto					
Filer:	Jan	James Henry Walters					
Attorney Docket Number:	A-4	A-468					
Filed as Large Entity							
Utility under 35 USC 111(a) Filing Fees							
Description		Fee Code	Quantity	Amount	Sub-Total in USD(\$)		
Basic Filing:	,						
Pages:							
Claims:							
Miscellaneous-Filing:							
Petition:							
Patent-Appeals-and-Interference:							
Post-Allowance-and-Post-Issuance:							

Publ. Fee- early, voluntary, or normal

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Extension-of-Time:				
Miscellaneous:				
	Total in USD (\$)			1810